

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	KIM et al.	Examiner: Young, Christopher G.
Serial No.:	10/827,513	Group Art Unit: 1756
Filed:	April 19, 2004	
For:	STENCIL MASK HAVING MAIN AND AUXILIARY STRUT METHOD OF FORMING THE SAME	

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT


Sir:

In response to the Office Action dated August 10, 2007, Applicants provisionally elect the claims of Group I (i.e., claims 1-13 and 50-51).

While the device of Group I and the method of Group II may be distinct as set forth by the Examiner, Applicants believe that simultaneous examination will not present an undue burden. For example, the claims of Group I are drawn to stencil masks and the claims of Group II are drawn to methods of making stencil masks. The subject matter of Group I and Group II can be found in class 430. Under such circumstances, the Examiner is encouraged to maintain the claims of Groups I and II in the same application. See, MPEP § 803.

Early and favorable consideration of the application is earnestly solicited.

Respectfully submitted,



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